

Reactivity of Perfluoro-n-alkyl Radicals with Reluctant Substrates.

Rates of Addition to R_FCH₂CH=CH₂ and R_FCH=CH₂

Bruno Delest, Alexander B. Shtarev, and William R. Dolbier, Jr.* Department of Chemistry, University of Florida, Gainesville, FL 32611-7200

Received 16 April 1998; revised 20 May 1998; accepted 29 May 1998

Abstract: Conditions for conducting competitive experiments involving slow reactions of perfluoroalkyl radicals have been defined. A revised value for the rate constant for hydrogen abstraction from Et₃SiH is reported [$(5.0\pm0.4) \times 10^5 \text{ M}^{-1}\text{s}^{-1}$], as are the rate constants for addition of the n-C₄F₉ radical to CH₂=CHCH₂C₄F₉ [$1.15\pm0.11 \times 10^6 \text{ M}^{-1}\text{s}^{-1}$] and to CH₂=CHC₄F₉ [$2.6\pm0.2 \times 10^5 \text{ M}^{-1}\text{s}^{-1}$] at 25 °C. © 1998 Elsevier Science Ltd. All rights reserved.

Having demonstrated the remarkable electrophilic reactivity of perfluoroalkyl radicals via comprehensive laser flash photolysis and competition-based kinetic studies of their alkene addition and hydrogen abstraction reactions, ^{1,2} we now are proceeding to extend such studies to substrates of lower reactivity.

In the earlier work, it was demonstrated, for example, that highly electrophilic perfluoro-n-alkyl radicals exhibit dramatically enhanced reactivity, relative to the analogous hydrocarbon radicals, in their additions to nucleophilic alkenes, such as 1-hexene $[k_{add}(R_{f}^{\bullet})/k_{add}(R_{H}^{\bullet})] \approx 30,000$. It was also shown that there was a quite respectable correlation of k_{add} with the ionization potentials of the 13 terminal olefins studied. ^{1a}

It was therefore expected that the π -bonds of the relatively electron-poor olefins, $CH_2=CHCH_2C_4F_9$ and $CH_2=CHC_4F_9$, with electronegative perfluoroalkyl substituents β and α , respectively, to the terminal π -bond, should be significantly less reactive than 1-hexene in undergoing additions by the highly electrophilic n- R_F * radical.

Although preliminary competition experiments confirmed this expected trend, it quickly became apparent that our normal approach for carrying out competition studies would not allow good quantitative data to be obtained for these systems. These preliminary studies demonstrated that, when measuring rates of such slow reactions, one must be *very* concerned about undesirable competitive reactions which are too slow to be of significance when one is measuring rates of fast reactions, but which can undermine the results from studies of slow reactions.

For example, in studies of fast reactions, it was our normal procedure to use C₆D₆ as the solvent, without significant resulting problems. In the current study, however, products of radical addition to benzene were observed when it was used as solvent, thus lowering the yields of products from the desired competition processes and complicating the ¹⁹F NMR spectra of the product mixtures to an unacceptable level.³

Another complication can arise when hydrogen atoms are donated to $R_{F^{\bullet}}$ from sources other than the added Et₃SiH.⁵ When both of the competitive processes under study are relatively slow (~ $10^5 M^{-1} s^{-1}$), then one has to worry about either the solvent or the alkene substrate itself competitively providing H-atoms to $R_{F^{\bullet}}$.⁸ In practice, one can readily determine when problems of this nature are intervening, because, in such situations the intercepts of the plots of [reduction product]/[addition product] versus [Et₃SiH]/[alkene] (which are used to obtain k_H/k_{add} ratios) will deviate significantly from their ideal value of zero.

In order to obtain reliable data, one must strive to control these side reactions and thus to eliminate the problems which cause the non-zero intercept. Problems deriving from the solvent can usually be controlled. Numerous solvents have been carefully evaluated, and three have emerged as being generally satisfactory, exhibiting little propensity to either give up H-atoms or undergo addition by R_F*. They are trifluoromethylbenzene, 1,4-bis(trifluoromethyl)benzene, and 1,3-bis(trifluoromethyl)benzene.¹⁰

When the alkene addend is a possible source of H-atoms, then the problem can be addressed another way, by maintaining its concentration constant for each data point in the experiment (varying only the concentration of Et_3SiH), thus making the rate of such alternate H-atom donation constant, with the intercept becoming a measure of this rate, and the slope retaining its integrity as a true measure of $k_H(Et_3SiH)/k_{add}(alkene)$ addend).

Reassessment and redetermination of $k_{\rm H}$ for H-transfer from triethylsilane.

In the light of our present enhanced understanding of those factors which can contribute to inaccuracy in these competition studies, ¹² we have gone back and reassessed *all* of our earlier experimental determinations of $k_{\rm H}$ values for H-transfer to n-R_F*. So doing, we have found that all but one conformed reasonably to our criteria for an ideal competitive process, that being the measurement of the relatively small $k_{\rm H}$ for Et₃SiH. In spite of the good mass balance obtained in that study, ⁷ and in spite of the good correlation coefficient for the plot of the data, the intercept deviated significantly from zero, and, because we had not maintained [1-hexene] constant in this experiment, the previously reported rate constant must be considered suspect and of unreliable accuracy.

We have now reexamined this competition, using the competition depicted in Scheme 1 and modifying the conditions of the study so as to minimize any sources of error. 1,3-Bis-(trifluoromethyl)benzene was used as solvent, strict pseudo first order conditions were maintained for both Et₃SiH

Scheme 1. Competition System for Determination of k_H for Et₃SiH

and 1-hexene, and the concentration of 1-hexene was maintained constant for each point in the plot. As the data in Table 1 indicate, mass balances were good, the correlation coefficient was good, and the intercept was small, but significant. Ratios obtained from individual points were also not indicative of any significant problematic trend. Lastly, the ¹⁹F NMR spectra of the crude product mixtures reflected formation of the reduction product 1, and the addition product 2 as the only products containing fluorine. Thus, one can be confident that the obtained slope accurately reflects the ratio of $k_{\rm H}/k_{\rm add}$.

Table 1. Competition data for the photoinitiated reduction of perfluoro-*n*-butyl radical by triethylsilane versus its addition to 1-hexene in 1,3-bis(trifluoromethyl)benzene at 25 °C.

Owiga	midol officulty i			
[C ₄ F ₉ I]	[1-hexene]	[Et ₃ SiH/[1-hexene]	[1]/[2]	Yield (%)
0.0431	0.463	4.330	0.283	96
0.0436	0.459	3.828	0.254	96
0.0441	0.468	3.319	0.220	94
0.0457	0.457	2.826	0.187	95
0.0431	0.468	2.234	0.155	94
0.0388	0.446	1.837	0.126	94

slope =
$$0.063 \pm 0.001$$

intercept = 0.012
correlation coefficient = $r^2 = 0.999$

If one assumes that k_{H} is the rate constant for H-atom abstraction from all sources other than the added reducing agent, $E_{13}SiH$, then the expression which describes the ratio of reduction product, 1, to addition product, 2, is eq (1).

$$\frac{k_{\text{H}}[\text{Et}_3\text{SiH}]}{k_{\text{add}}[\text{alkene}]} + \frac{k_{\text{H}}'[\text{Other H-atom sources}]}{k_{\text{add}}[\text{alkene}]} = \frac{[1]}{[2]} \quad \text{eq (1)}$$

In the special situation where the alkene addend is the only reasonable other H-atom source, the equation reduces to eq (2), where the slope will equal $k_{\rm H}/k_{\rm add}$, and the intercept will equal $k_{\rm H}/k_{\rm add}$.

$$\frac{k_{\text{H}}[\text{Et}_3\text{SiH}]}{k_{\text{add}}[\text{alkene}]} + \frac{k_{\text{H}}'}{k_{\text{add}}} = \frac{[1]}{[2]} \quad \text{eq (2)}$$

Taking the slope to be equal to $k_{\rm H}/k_{\rm add}$, and using the lfp-obtained value of $k_{\rm add}$ for the addition of n- C_7F_{15} ° to 1-hexene $(7.9 \pm 0.7 \times 10^6 \ {\rm M}^{-1}{\rm s}^{-1})^{1a}$, one obtains a value of $5.0 (\pm 0.4) \times 10^5 \ {\rm M}^{-1}{\rm s}^{-1}$ as the rate constant $(k_{\rm H})$ for abstraction of a hydrogen atom from Et₃SiH by a generic n- $R_{\rm F}$ ° radical. This value differs slightly from the value of $7.5 (\pm 0.7) \times 10^5 \ {\rm M}^{-1}{\rm s}^{-1}$ which we had reported in 1995.

Although one must be careful about giving the intercept too much quantitative significance, following through with the above logic leads to the conclusion that $k_{\rm H}'/k_{\rm add}=0.012$, with the rate constant for H-atom abstraction from 1-hexene therefore being ca. 9 x $10^4{\rm M}^{-1}{\rm s}^{-1}$. Brace independently obtained a very similar value of 0.01 for the ratio of $k_{\rm H}'/k_{\rm add}$ for 1-heptene in 1963, ¹³ so we can be reasonably confident about our interpretation of the data in this case.

Addition of n-C₄F₉• to CH₂=CHCH₂C₄F₉ and CH₂=CHC₄F₉.

The competitive studies of addition of perfluoro-n-butyl radical to the relatively unreactive alkenes, 4,4,5,5,6,6,7,7,7-nonafluoro-1-heptene (3) and 3,3,4,4,5,5,6,6,6-nonafluoro-1-hexene (4), were carried out in trifluoromethylbenzene and 1,3-bis-(trifluoromethyl)benzene, respectively, using Et₃SiH as the hydrogen transfer agent as per Scheme 2. Because of the strengthening effect of a perfluoroalkyl group on neighboring

Scheme 2. Competition Studies to determine k_{add} values for alkenes 3 and 4

C-H bonds,¹⁴ neither alkene was expected to donate hydrogen atoms at a rate competitive with Et₃SiH, and the small intercepts which were observed in the plots of data from Tables 2 and 3 using eq. (3) are consistent with this expectation.

Table 2. Competition data for the photoinitiated addition of perfluoro-*n*-butyl radical to 4,4,5,5,6,6,7,7,7-nonafluoroheptene (3) versus its reduction by triethylsilane in α,α,α -trifluoromethyl-benzene at 25 °C.

$[C_4F_9I]$	$[CH_2=CHCH_2C_4F_9]$	[Et ₃ SiH]/[3]	[1] / [5]	Yield (%)
0.043	0.541	2.44	1.11	92
0.043	0.619	1.98	0.894	84
0.043	0.699	1.624	0.728	99
0.043	0.752	1.423	0.668	98
0.045	0.654	1.591	0.754	106

Slope =
$$0.434 (\pm 0.02)$$

Intercept = $0.04 (\pm 0.04)$
 $r^2 = 0.992$

Table 3. Competition data for the photoinitiated addition of perfluoro-*n*-butyl radical to 3,3,4,4,5,5,6,6,6-nonafluoro-1-hexene (4) versus reduction by triethylsilane in 1,3-bis(trifluoromethyl)benzene at 25 °C.

[C ₄ F ₉ I]	[CH ₂ =CHC ₄ F ₉]	[Et ₃ SiH]/[4]	[1] / [6]	Yield (%)
0.051	1.558	0.385	0.80	100
0.052	1.566	0.479	0.902	96
0.047	1.569	0.570	1.118	99
0.050	1.565	0.699	1.302	95
0.051	1.567	0.820	1.58	95
0.049	1.570	1.012	2.00	91

Slope = 1.93 (
$$\pm 0.09$$
)
Intercept = 0.01 (± 0.06)
r² = 0.992

Comparative Reactivities of Fluorinated and Unfluorinated 1-Alkenes

	$k_{\rm add}(M^{-1}s^{-1})$	Krei
	7.9 (0.7) x 10 ⁶	30
C_4F_9	1.15 (0.11) x 10 ⁶	4. 4
∕C₄F ₉	2.6 (0.2) x 10 ⁵	1

It can be seen that placing a perfluoroalkyl substituent proximate to a terminal π -bond has a significant detrimental effect with respect to its reactivity towards addition by a perfluoro-n-alkyl radical. This effect is no doubt largely the result of the large inductive electron-withdrawing effect of the perfluoroalkyl substituent on the inherent nucleophilicity of the hydrocarbon alkene. It has been demonstrated, by the correlation of k_{add} with alkene ionization potential in our earlier lfp study, ^{1a} that the major transition state orbital interaction for addition of the highly electrophilic perfluoroalkyl radical to alkenes is that between the SOMO of the radical and the HOMO of the alkene. Because of its great electronegativity, a proximate perfluoroalkyl substituent would certainly be expected to lower the energy of the alkene HOMO and thus make its π -bond less reactive towards addition by the R_F - radical.

When the C₄F₉ substituent is placed at the allylic position as in 3, the rate constant for addition of the $R_{F^{\bullet}}$ radical is ~ 7 times smaller than that for its respective addition to 1-hexene. Indeed, its rate constant is less than that for addition of $R_{F^{\bullet}}$ to the acknowledged electrophilic olefin, acrylonitrile ($k_{add} = 1.6 \times 10^6 \text{ M}^{-1}\text{s}^{-1}$). ^{1a}

The rate constant for addition to 4, where the C₄F₉ substituent is directly attached to the double bond, is the *smallest* rate constant for alkene addition that we have yet measured, either by lfp or by competition methods. Being able to obtain an accurate measure of this relatively small rate constant was an essential step in the process of extending our competition studies to increasingly slow reactions of perfluoroalkyl radicals. Indeed, within our current studies of inter- and intramolecular C-H abstraction processes we have now been able to reliably measure rate constants in the 10³ range!⁹ These results will be reported in the near future.

Acknowledgment. Support of this research in part by the National Science Foundation is gratefully acknowledged. Support of Bruno Delest by Elf Aquitane, Inc., under the Coopérants du Service National Program, is also acknowledged with thanks.

EXPERIMENTAL

General Procedure for the Kinetic Competition Experiments of Hydrogen Abstraction from Triethylsilane versus Addition to Olefins.

Into each of a set of pyrex NMR tubes flushed with nitrogen was added a known volume of the solvent. The quantities of silane, olefin, and perfluoro-n-butyl iodide in each sample were varied, with the respective amounts being weighed to determine their concentration. A thin, sealed glass tube containing a solution of (trifluoromethyl)trimethylsilane in C_6D_6 was placed in each tube as an external standard for measuring yields by ¹⁹F NMR. Each NMR tube to be used for kinetics was frozen in i-PrOH/CO₂ mixture and subjected to three successive freeze-pump-thaw cycles followed by pressurization with nitrogen, and then finally sealed with a rubber septum and secured with parafilm tape. The tubes were then subjected to UV photolysis in a Rayonet reactor (254 nm) at room temperature until there was complete consumption of starting material, as monitored by ¹⁹F NMR. The k_H/k_{add} ratios were determined from the plot of [Reduction Product]/[Addition Product] (as determined by ¹⁹F NMR) versus [Et₃SiH]/[Olefin]. Yields were determined by integration of product resonances versus the external standard, (trifluoromethyl)trimethylsilane.

1,1,1,2,2,3,3,4,4,8,8,9,9,10,10,11,11,11-Octadecafluoroundecane (5). ¹H NMR δ (CDCl₃) 2.17 (tt, 4H, CH₂CF₂, ³ J_{HF} = 18.5 Hz, ³ J_{HH} = 7.8 Hz), 1.96 (m, 2H); ¹⁹F NMR (C₆D₆) δ -81.5 (t, 6F, J = 9.7 Hz), -115.2 (t, 4F, J = 13.3 Hz), -124.6 (t, 4F, J = 4.8 Hz), -126.3 (m, 4F); HRMS (CI) Calcd for C₁₁H₅F₁₇ ([M-HF]⁺) 460.0120; Found: 460.0096; LRMS (EI) m/z 461 (1%) [M-F]⁺, 441 (3) [MH-2HF]⁺, 421 (2) [MH-3HF]⁺, 291 (44), 271 (20), 227 (100), 207 (21), 177 (14), 163 (18), 145 (11), 113 (13), 95 (19), 84 (16); 69 (17).

1,1,1,2,2,3,3,4,4,7,7,8,8,9,9,10,10,10-Octadecafluorodecane (6). ¹H NMR (CDCl₃) δ 2.40 (m, J = 12.4, 4.7 Hz); ¹⁹F NMR (CDCl₃) δ -81.56 (t, 6F, J = 9.8 Hz), -115.45 (tm, 4F, J = 12.8 Hz), -124.8 (m, 4F), -126.54 (m, 4F); ¹³C NMR (CDCl₃) δ 23.0 (tm, CH₂, J = 22.9 Hz) 106-124 (m, CF₂, CF₃ signals); HRMS (CI) Calcd for C₁₀H₃F₁₆ ([MH-2HF]⁺) 426.9979; Found: 426.9970; LRMS (EI) m/z 445 (3), 427 (100) [MH-2HF]⁺, 407 (79) [MH-3HF]⁺, 357 (23), 277 (20), 257 (39), 213 (78), 195 (38), 163 (82), 145 (34), 113 (41), 95 (53), 69 (38).

The characterizations of all other products have been reported previously. 1a,7

REFERENCES AND FOOTNOTES

- (a) Avila, D. V.; Ingold, K. U.; Lusztyk, J.; Dolbier, W. R., Jr.; Pan. H.-Q.; Muir, M. J. Am. Chem. Soc. 1994, 116, 99-104, (b) Dolbier, W. R., Jr.; Rong, X. X.; Pan, H.-Q.; Smart, B. E. J. Am. Chem. Soc. 1994, 116, 4521-4522; (c) Avila, D. V.; Ingold, K. U.; Lusztyk, J.; Dolbier, W. R., Jr.; Pan, H.-Q. J. Org. Chem. 1996, 61, 2027-2030; (d) Avila, D. V.; Ingold, K. U.; Lusztyk, J.; Dolbier, W. R., Jr.; Pan, H.-Q. Tetrahedron 1996, 52, 12351-12356; (e) Dolbier, W. R., Jr.; Li, A. R. J. Chem. Soc., Perkin Trans. 2 1998, 79-82; (f) Dolbier, W. R., Jr.; Rong, X. X.; Bartberger, M. D.; Koroniak, H.; Smart, B. E.; Yang, Z.-Y. J. Chem. Soc., Perkin Trans. 2 1998, 219-232.
- Dolbier, W. R., Jr. Chem. Rev. 1996, 96, 1557-1595; (b) Dolbier, W. R., Jr. Topics in Current Chem. 1997, 192, 97-163.
- 3. The bimolecular rate constant for addition of n-C₄F₉• radical to benzene has been estimated by Minisci et al⁴ to be $2.1 2.4 \times 10^5 \,\mathrm{M}^{-1}\mathrm{s}^{-1}$.
- 4. Bravo, A.; Bjørsvik, H. R.; Fontana, F.; Liquori, L.; Mele, A.; Minisci, F. J. Org. Chem. 1997, 62, 7128-7136.
- 5. Indeed, not all of the hydrogen which is transferred from Et₃SiH to alkyl and perfluoroalkyl radicals derives from the Si-H bond. It has been estimated that for transfer to an alkyl radical as much as 40% of the hydrogen derives from the ethyl groups,⁶ and for transfer to a perfluoro-n-alkyl radical, ~ 4%.⁷
- 6. Chatgilialoglu, C.; Ferrari, C.; Lucarini, M. J. Org. Chem. 1983, 58, 249-251.
- 7. Dolbier, W. R., Jr.; Rong, X. X. J. Fluorine Chem. 1995, 72, 235-240.
- 8. For example, if one simply attempts to reduce n-C₄F₉I to n-C₄F₉D using Et₃SiD in pentane solvent, one obtains a product ratio of n-C₄F₉H/n-C₄F₉D = 1.34, with most of the protiated product deriving from H-atom transfer from the pentane solvent!
- 9. Shtarev, A.; Dolbier, W. R., Jr.; Smart, B. E.; Yang, Z. Y. unpublished results.
- 10. Because of its beneficial qualities as a "fluorous" solvent, trifluoromethylbenzene has already acquired a very favorable reputation as a solvent for free radical reactions.¹¹
- 11. Curran, D. P.; Haddida, S. J. Am. Chem. Soc. 1996, 118, 2531-2532.
- 12. We thank a referee of an earlier paper in this series for causing us to examine more closely the problem of non-zero intercepts.
- 13. Brace, N. O. J. Org. Chem. 1963, 28, 3093-3102.
- 14. Dolbier, W. R., Jr.; Bartberger, M. D.; Lusztyk, J.; Ingold, K. U. Tetrahedron 1997, 53, 9857-9880.